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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DOCKET NO.	CONFIRMATION NO.	
10/710,199	06/25/2004	Chih-Wei Yang	13875-US-PA	4198	
31561 7	590 12/22/2005		EXAMINER		
JIANQ CHYUN INTELLECTUAL PROPERTY OFFICE			LE, DUNG ANH		
7 FLOOR-1, NO. 100 ROOSEVELT ROAD, SECTION 2 TAIPEI, 100			ART UNIT	PAPER NUMBER	
			2818		
TAIWAN			DATE MAILED: 12/22/2009	DATE MAILED: 12/22/2005	

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)			
Office Action Comme	10/710,199	YANG ET AL.			
Office Action Summary	Examiner	Art Unit			
	DUNG A. LE	2818			
The MAILING DATE of this communication apports of the second for Reply	ears on the cover sheet with the c	orrespondence address			
A SHORTENED STATUTORY PERIOD FOR REPLY WHICHEVER IS LONGER, FROM THE MAILING DA - Extensions of time may be available under the provisions of 37 CFR 1.13 after SIX (6) MONTHS from the mailing date of this communication. - If NO period for reply is specified above, the maximum statutory period w - Failure to reply within the set or extended period for reply will, by statute, Any reply received by the Office later than three months after the mailing earned patent term adjustment. See 37 CFR 1.704(b).	ATE OF THIS COMMUNICATION 6(a). In no event, however, may a reply be time ill apply and will expire SIX (6) MONTHS from cause the application to become ABANDONE!	lely filed the mailing date of this communication. D (35 U.S.C. § 133).			
Status					
1) Responsive to communication(s) filed on 20 Oc	Responsive to communication(s) filed on 20 October 2005.				
2a) ☐ This action is FINAL . 2b) ☑ This	action is non-final.				
3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is					
closed in accordance with the practice under E	x parte Quayle, 1935 C.D. 11, 45	53 O.G. 213.			
Disposition of Claims					
 4) Claim(s) 14-20 is/are pending in the application. 4a) Of the above claim(s) is/are withdrawn from consideration. 5) Claim(s) is/are allowed. 6) Claim(s) 14-20 is/are rejected. 7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction and/or election requirement. 					
Application Papers					
9)⊠ The specification is objected to by the Examiner 10)⊠ The drawing(s) filed on 25 June 2005 is/are: a) Applicant may not request that any objection to the of Replacement drawing sheet(s) including the correction of the oath or declaration is objected to by the Examiner	☑ accepted or b)☐ objected to drawing(s) be held in abeyance. See on is required if the drawing(s) is obj	e 37 CFR 1.85(a). ected to. See 37 CFR 1.121(d).			
Priority under 35 U.S.C. § 119					
12) Acknowledgment is made of a claim for foreign a) All b) Some * c) None of: 1. Certified copies of the priority documents 2. Certified copies of the priority documents 3. Copies of the certified copies of the prioriapplication from the International Bureau * See the attached detailed Office action for a list of	have been received. have been received in Application ity documents have been received (PCT Rule 17.2(a)).	on No ed in this National Stage			
Attachment(s)					
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-948) Information Disclosure Statement(s) (PTO-1449 or PTO/SB/08) Paper No(s)/Mail Date 	4) Interview Summary Paper No(s)/Mail Da 5) Notice of Informal Pa 6) Other:	(PTO-413) ate atent Application (PTO-152)			

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DETAILED ACTION

Oath/Declaration

The oath/declaration filed on 6/25/2005 is acceptable.

Election/Restriction

Examiner confirms that Applicants elected to prosecute Claims 14-20 and have canceled Claims 1-13.

Information Disclosure Statement

This office acknowledges of the following items from the Applicant:

Information Disclosure Statement (IDS) filed on 6/25/2005 and made of record.

The references cited on the PTOL 1449 form have been considered.

Specification

The specification is objected to for the following reason:

The title of the invention is not descriptive. A new title is required that is clearly indicative of the invention to which the claims are directed (see MPEP § 606.01).

A new abstract is required that is clearly indicative the invention to which the claims are directed.

Note that, the claims are directed to semiconductor device instead of to a method of making a semiconductor device.

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The specification has been checked to the extent necessary to determine the presence of all possible minor errors. However, the applicant's cooperation is requested in correcting any errors of which applicant may become aware in the specification.

Claim Rejections

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claims 14- 16 and 19-20 are rejected under 35 U.S.C. 103 (a) as being unpatentable over Eppich et al. in view of Forbes et al. (2005/0023602 A1).

Eppich et al. teach a MOS transistor, comprising:

- a substrate 16,
- a gate dielectric layer 22 on the substrate,
- a stacked gate on the gate dielectric layer, comprising,

from bottom to top, a first barrier layer 24, an interlayer 30, a work-function-dominating layer 32, and second barrier layer 34 and a poly-si layer a source/drain 52 in the substrate beside the gate (Figs. 2- 6 and related text).

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Eppich et al. do not teach a poly-si layer on the second barrier.

Forbes et al. teach a poly-si layer 213 on the second barrier 217 (Fig. 2 and related text).

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to form a poly-si layer in Eppich et al. 's structure/device in order to avoid the danger of metal diffusion into a work-function-dominating layer and the gate dielectric layer.

Regarding claim 15, wherein the interlayer 30 [0038] includes a material capable of controlling a crystal orientation of the work-function-dominating layer to adjust a work function of the work-function-dominating layer.

Regarding claim 16, wherein the interlayer includes a material capable of wetting a surface of the first barrier layer [0038].

Regarding claim 17, wherein a thickness of the interlayer 30 is smaller than a thickness of the work-function-dominating layer 32 (figs 2-6).

Regarding claim 19, wherein the gate dielectric layer comprises a high-K dielectric layer 22 [0035].

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Regarding claim 20, further comprising:

a spacer 48 on a sidewall of the gate; and

a pair of lightly doped drains in the substrate,

wherein the source/drain is in the substrate beside the spacer, and the lightly doped drains are in the substrate beside the gate connecting with the source/drain (Fig. 6).

Claim Rejections - 35 USC § 103

The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:

(a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.

Claim 18 is rejected under 35 U.S.C. 103 (a) as being unpatentable over Eppich et al. in view of Forbes et al. (2005/0023602 A1) and further in view of the remark.

Eppich et al. in view of Forbes et al. teach the claimed invention as applied to claim 14 except for a thickness of the work-function-dominating layer 110 is larger than a total thickness of the first and second barrier layers 104/112 as cited in current claim.

However, it would have been obvious to one of ordinary skill in the art at the time the invention was made to form the work-function-dominating layer having a thickness

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is larger than a total thickness of the first and second barrier layers, since it has been held that where the general conditions of a claim are disclosed in the prior art, discovering the optimum or working ranges involves only routine skill in the art.

When responding to the office action, Applicants' are advice to provide the examiner with the line numbers and page numbers in the application and/or references cited to assist the examiner to locate the appropriate paragraphs.

A shortened statutory period for response to this action is set to expire 3 (three) months and 0 (zero) day from the day of this letter. Failure to respond within the period for response will cause the application to become abandoned (see M.P.E.P 710.02(b)).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dung A. Le whose telephone number is (571) 272-1784. The examiner can normally be reached on Monday-Tuesday and Thursday 6:00am- 4:00 pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The central fax phone numbers for the organization where this application or proceeding is assigned are (571)272-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status

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information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

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DETAILED ACTION

Election/Restrictions.

Claims 1-20 are pending in this application.

Restriction to one of the following inventions is required under 35 U.S.C. 121:

Group I. Claims 14-20, drawn to a semiconductor device, classified in class 257, subclass 24.

Group II. Claims 1-13, drawn to process of making a semiconductor device, classified in class 438, and subclass 197.

The inventions are distinct, each from the other because of the following reasons:

Inventions II and I are related as process of making and product made. The inventions are distinct if either or both of following can be shown: (1) that the process as claimed can be use to make other and materially different product or by hand, or (2) that process as claimed can be made by another and materially different process. (MPEP § 806.05(f)). In the instance case unpatentabilities of the group I invention would not necessarily imply unpatentability of the group II invention, since the device of the group I invention could be made by the processes materially different from those of the group II invention, for example, in the claim 3, the product as claimed can be made by another and materially different process such as the interlayer is formed through the use a Pulsed Laser Deposition (PLD) method instead of PDV, ALD or MOCVD.

Because these inventions are distinct for the reasons given above and have acquired a separate status in the art as shown by their different classification, the fields of search are not co-extensive. Therefore, separate examination would be required and restriction for examination purposes as indicated is proper.

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Applicant is reminded that upon the cancellation of claims to a non-elected invention, the inventorship must be amended in compliance with 37 CFR 1.48(b) if one or more of the currently named inventors is no longer an inventor of at least one claim remaining in the application. Any amendment of inventorship must be accompanied by a diligently filed petition under 37 CFR 1.48(b) and by the fee required under 37 CFR 1.17(h).

Conclusion

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Dung A. Le whose telephone number is (571) 272-1784. The examiner can normally be reached on Monday-Friday 8:00am- 4:30pm.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571) 272-1787. The fax phone numbers for the organization where this application or proceeding is assigned are (703) 872-9306 for regular communications and (703) 872-9306 for After Final communications.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

DUNG A. LE Primary Examiner Art Unit 2818